



CPRA Harry Boothman Bursary Follow Up Report

Name:	_____		
Address:	_____		
City/Town:	_____	Province:	_____
Postal Code:	_____	Bus. Phone:	_____
Cell Phone:	_____	Home Phone:	_____
Email Address:	_____		
Current Employer:	_____		
Current Job Title:	_____		

Amount of bursary funding approved: \$ _____

Deadline for submission of follow up report is within three (3) months of the completion date of the Professional Development opportunity.

Please share your learnings and provide a brief summary on the Professional Development opportunity you attended with the support of the Harry Boothman Bursary. This information may be utilized for promotional purposes within CPRA communications, please limit your response to 250 words. Potential subject areas recommended include:

- A brief description of Professional Development opportunity outline and its activities.
- Description of your intended learning outcomes and how they were achieved.
- Identifying how will you implement the skills and knowledge gained through this Professional Development opportunity in the future.
- Sharing how you benefited from participation in this scholarship program.

Attach additional pages if required.



Provide a summary of sources of funding and expenses that were incurred.
(Please attach receipts to substantiate your expenditures)

Sources of Funding (Identify all that apply)

CPRA Bursary \$ _____
 Self Help – Personal \$ _____
 Self Help – Employer \$ _____
 Self Help – Grants/Other \$ _____
 Other (please specify) \$ _____

Total \$ _____

Expenditures (Identify all that apply)

Registration Fees \$ _____
 Books and Manuals \$ _____
 Travel \$ _____
 Accommodations \$ _____
 Other (please specify) \$ _____
 Taxes \$ _____

Total \$ _____

Signature of Recipient: _____

Please return this completed form and receipts to:
 CPRA Harry Boothman Bursary
 1180 Walkley Road, Ottawa, ON, K1V 2M5

Or, electronically to: mjay@cpra.ca

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